

## Photoemission (2) Surface Science

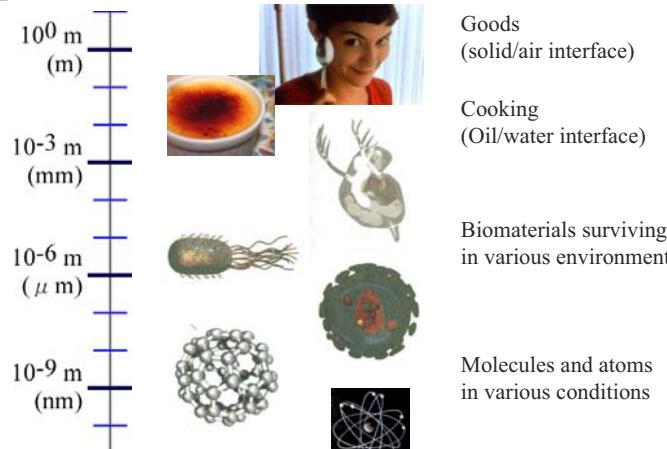
Iwao Matsuda

LASOR, Synchrotron Radiation Laboratory,  
the Institute for Solid State Physics,  
the University of Tokyo, JAPAN

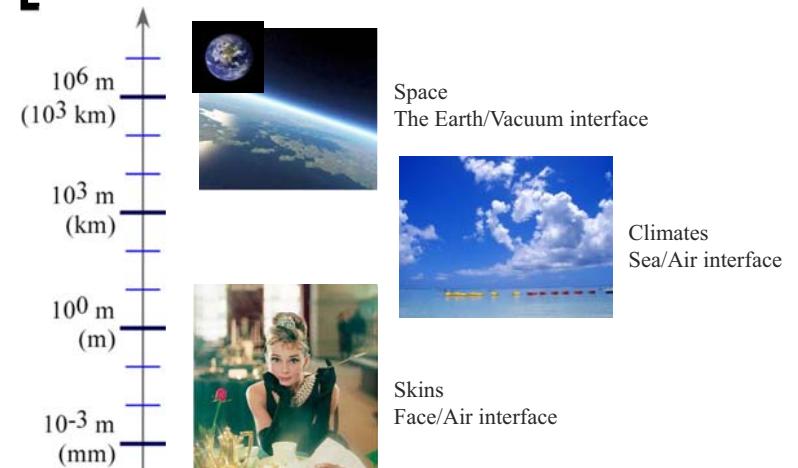
<http://imatsuda.issp.u-tokyo.ac.jp/index.htm>



## Surface/Interface in scales



## Surface/Interface in scales



## Surface/Interface in scales

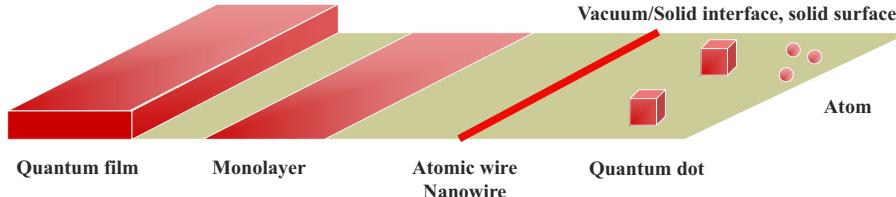
- Things go on in a non-uniform system in any scale.

And there're always interfaces (surfaces) that play their roles.

- Solid/Liquid
- Solid/Gas
- Liquid/Gas
- Solid/Solid
- Solid/Vacuum
- .....



# My playground



Nanometer-scale and atomic-scale structures on a solid surface.

## Chemistry

- Catalysis reaction
- Ecology
- Solutions for energy-shortage problem

Advantage of surface science:

- Visualization of atomic configuration and electron density (LDOS) distribution in atomic scale
- Direct determination of electronic structure (band, Fermi surface, etc...)



## Physics

- Low-dimensional physics
- Quantum dynamics
- New physics

## Applied Physics

- Bottom-up nanotechnology
- Atom technology
- New technological developments



# Surface Analyses

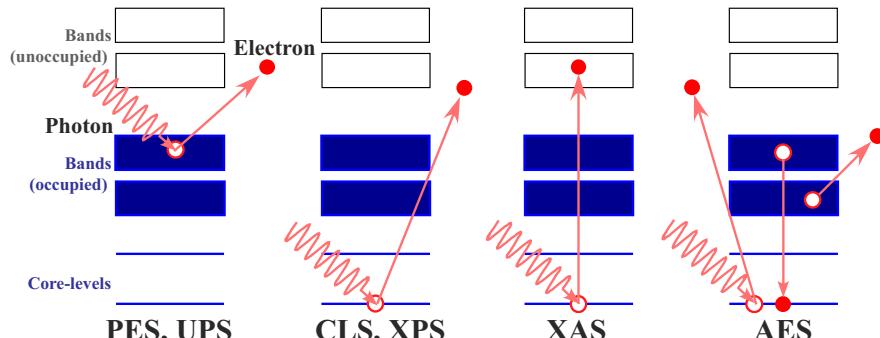
## Photon-in / Particle-out

Photoemission Spectroscopy (PES), Ultraviolet Photoelectron Spectroscopy (UPS)

Core-level Spectroscopy (CLS), X-ray Photoelectron Spectroscopy (XPS)

X-ray Absorption Spectroscopy (XAS)

Auger Electron Spectroscopy (AES)



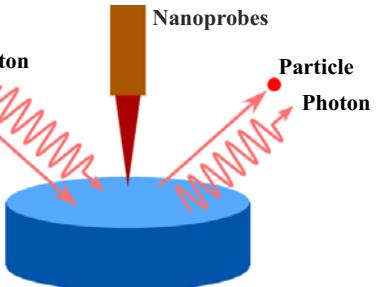
# Surface Analyses

## Varieties of Surface analysis techniques

Given examples.....

### Nanoprobes

Scanning Tunneling Microscope (STM)  
Atomic Force Microscope (AFM)



### Particle-in / Particle-out

He scattering

Low-energy electron Diffraction (LEED)  
Transmission Electron Diffraction (TED)  
Reflection High-Energy Electron Diffraction (RHEED)  
Reflection High-Energy Positron Diffraction (RHEPD)

### Photon-in / Photon-out

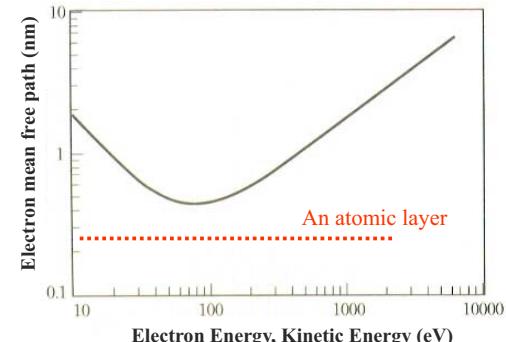
Grazing-angle incident X-ray Diffraction (GIXRD)



# Spectroscopy with VUV~SX

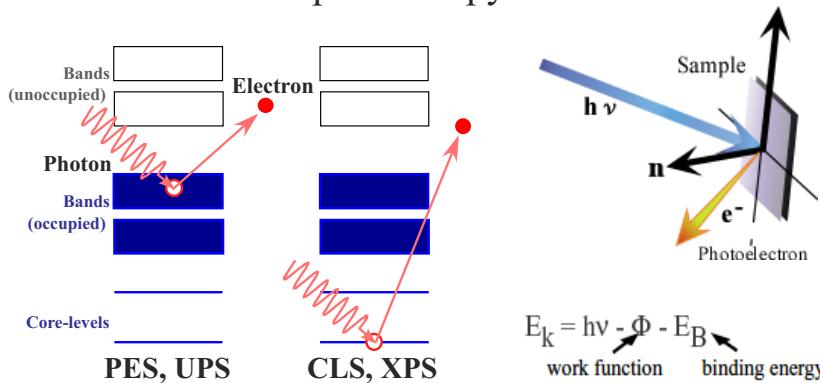
## ■ Electron mean free path

surface-sensitive ~ bulk sensitive



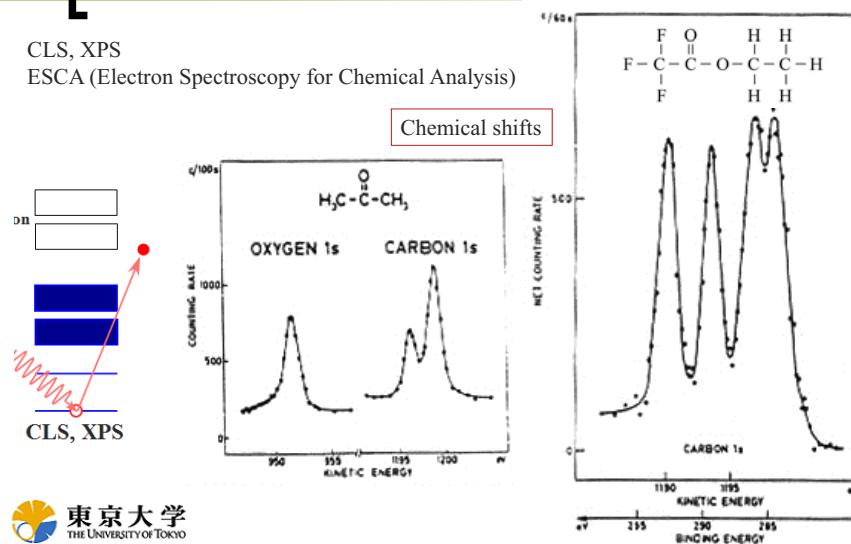
## Probing electronic states

### Photoelectron spectroscopy

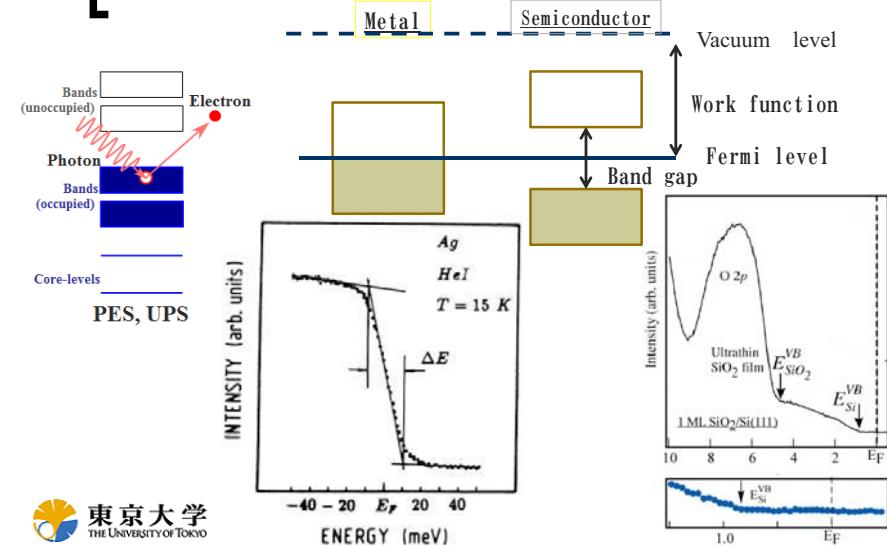


## Probing electronic states

CLS, XPS  
ESCA (Electron Spectroscopy for Chemical Analysis)

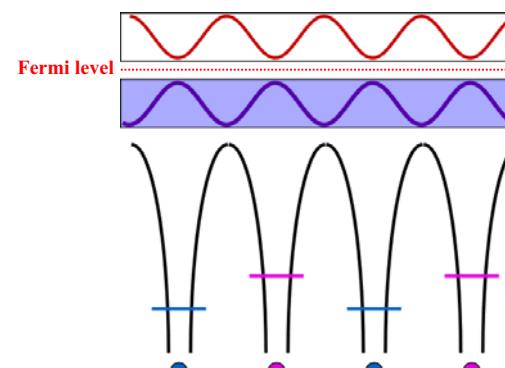


## Probing electronic states



## What can be probed by photoemission

Vacuum level



## Spectroscopy with VUV~SX

- Energy range to probe
  - atomic structure
  - electronic structure
  - spin structure

- Diffraction
- Absorption (EXAFS,NEXAFS,MCD)
- Photoemission (ARPES, CLS, Spin-resolved PES, PED)
- X-ray emission

- surface sensitive ~ bulk sensitive
- specification of all elements
- structure determination with high accuracy
- spin magnetic moment, orbital magnetic moment
- direct determination of spin-resolved electronic structure



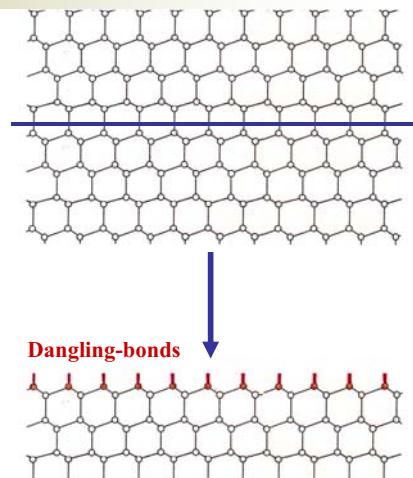
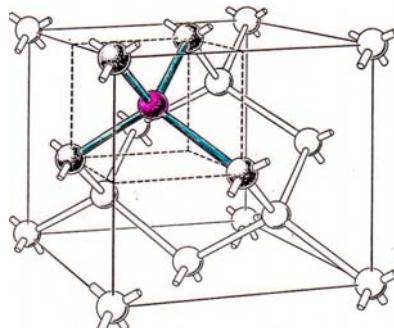
*Semiconductor surface*

*Atomic structure*

## Cutting (expectation)

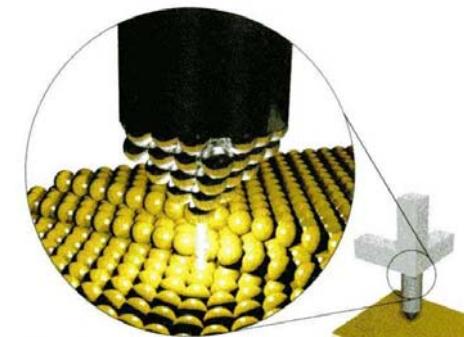
Silicon (Si)

Diamond structure

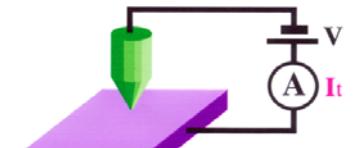


## Scanning Probe Microscope

### Scanning Tunneling Microscope (STM)



Rohrer and Binnig (1982)

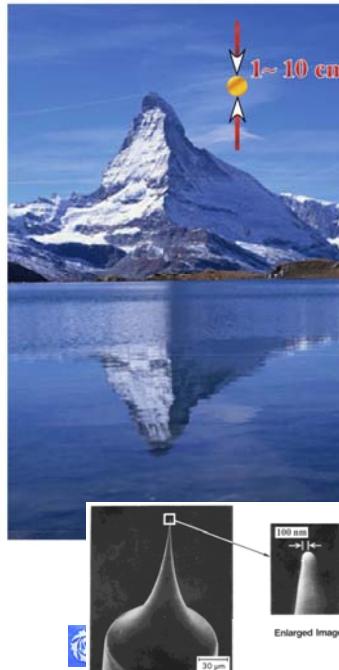
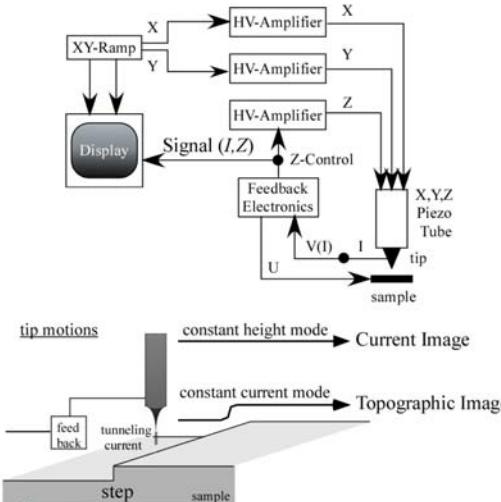


$$\text{Tunneling Current } I_t \propto f(v) \cdot e^{-\sqrt{\Phi} \cdot d}$$

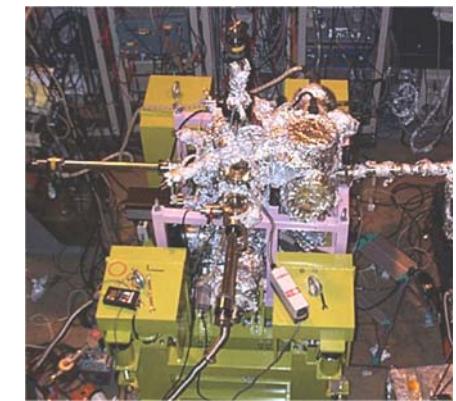


# [ STM ]

Scanning Tunneling Microscope (STM)



# [ Scanning Tunneling Microscope ]



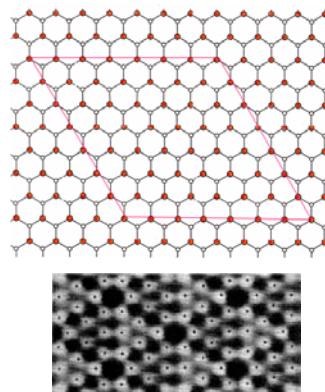
An experimental chamber

- the Ultra High Vacuum condition
- Isolation of vibration
- Sample surface preparation

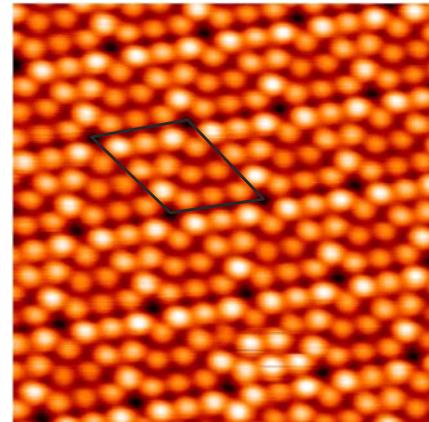


# [ An STM image ]

Ideal surface



Real surface (STM image)



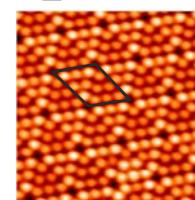
G. Binnig, H. Rohrer *et al.*, Phys. Rev. Lett. **50** (1983) 120.



The  $7a_{1\times 1}$  ( $a_{1\times 1}$ : $3.8\text{ \AA}$ ) periodicity:  
The Si(111)-7x7 surface

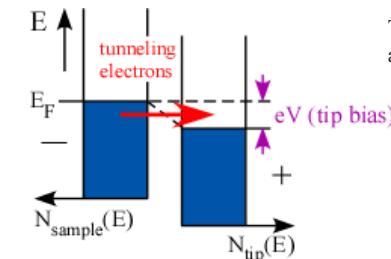


# [ Scanning Tunneling Microscope ]



It's just an image of atomic scale protrusions measured through tunneling currents.

What are they?



Tunneling currents between unoccupied states and occupied states near Fermi level ( $E_F$ ).

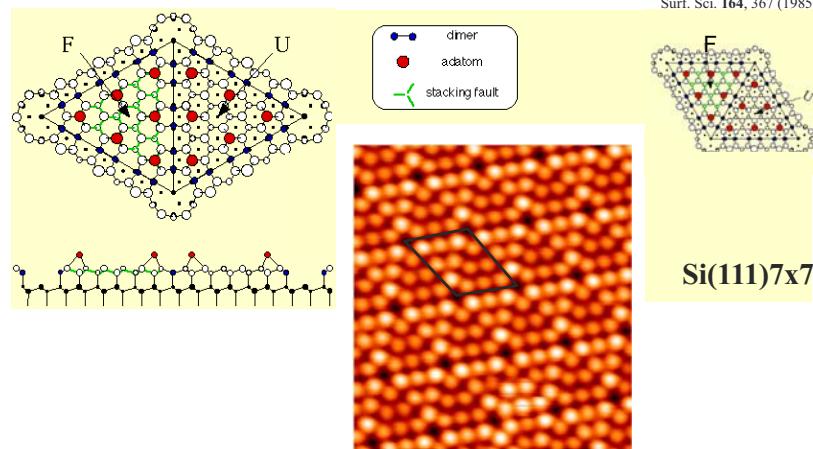


Protrusions in STM could be surface atoms

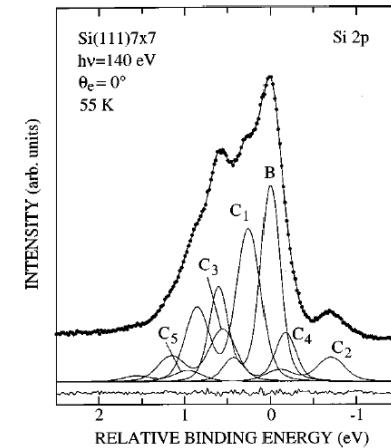


## Atomic Structure

### Dimer-Adatom-Stacking Fault (DAS) model



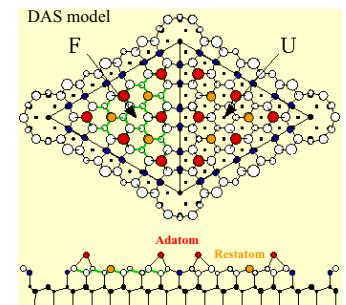
## Core-levels



R. I. G. Uhrberg *et al.*,  
Phys. Rev. B **58**, R1730 (1998).

### Surface components

- C<sub>1</sub>: Atom binding to the adatom
- C<sub>2</sub>: Rest atom
- C<sub>3</sub>: Adatom
- C<sub>4</sub>: Dimer atom
- C<sub>5</sub>: Surface impurity atom



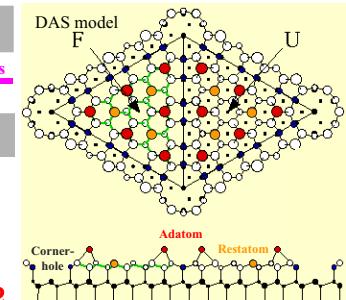
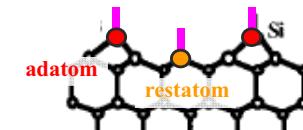
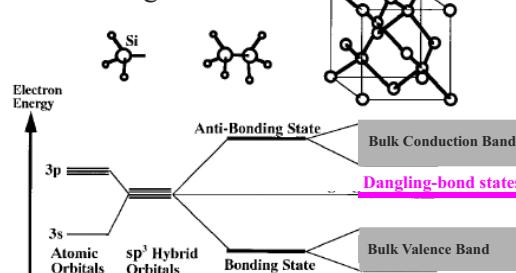
## Semiconductor surface

### Electronic structure



## Electronic states of Si(111)7x7

### Bonding states



# of dangling bonds  
in the 7x7 unit cell

adatom: 12

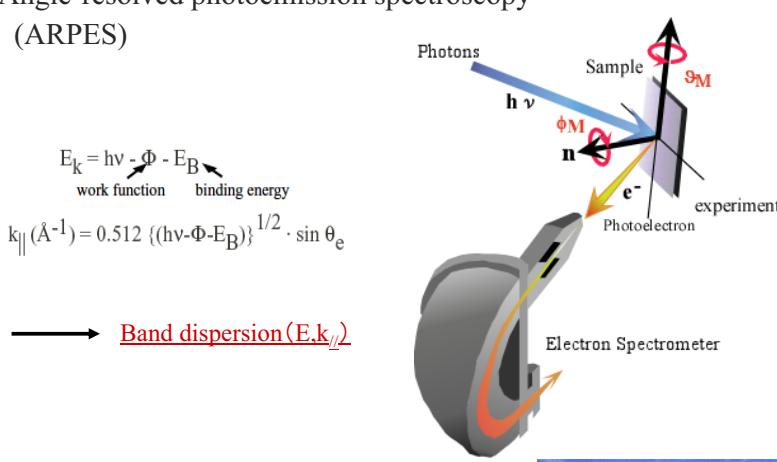
restatom: 9

corner-hole: 1



## Band mapping

- Angle-resolved photoemission spectroscopy (ARPES)



→ Band dispersion ( $E_k \perp$ )

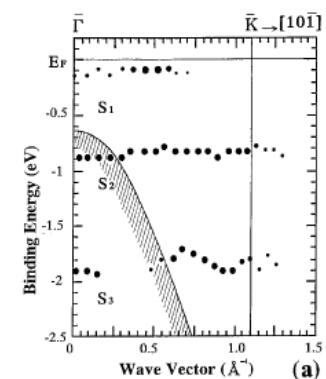
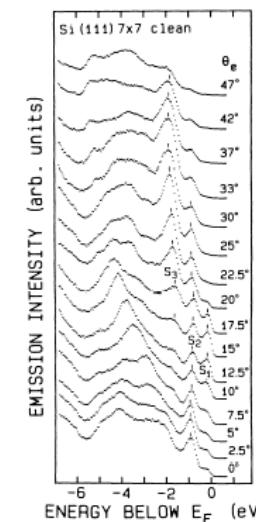
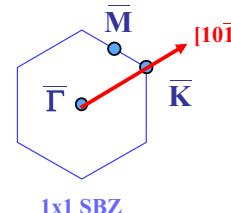


## ARPES measurement

Si(111)7x7

Conventional measurements

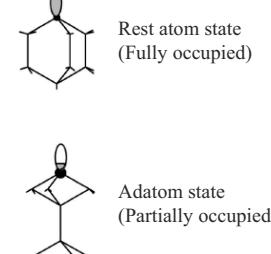
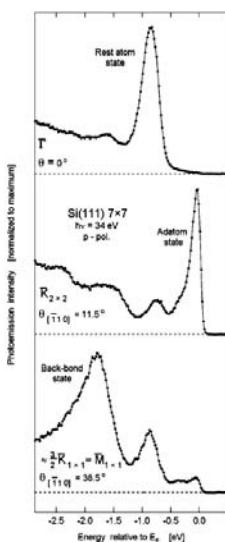
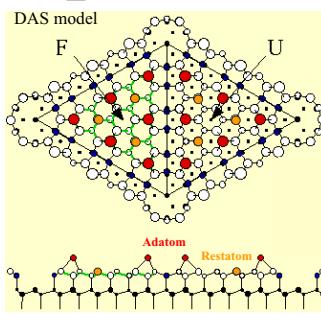
Energy spectra at various angles along symmetric crystal axis



P. Martensson *et al.*,  
Phys. Rev. B **36**, 5974 (1987).



## Dangling bonds



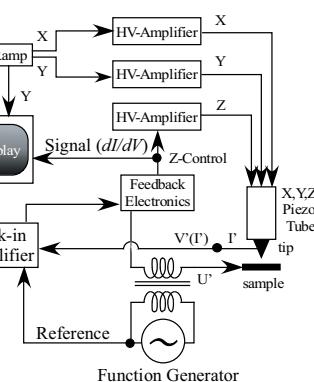
- Charge transfer  
- Metallic surface

R. Losio *et al.*,  
Phys. Rev. B **61**, 10845 (2000).



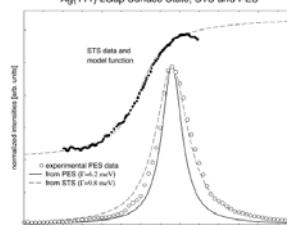
## Scanning Tunneling Spectroscopy

Scanning Tunneling Spectroscopy (STS),  $dI/dV$



G. Nicolay *et al.*, Phys. Rev. B **62** 1631 (2000).

Ag(111) LGap Surface State, STS and PES



$$\text{Bias Modulation: } V' = V + \varepsilon \sin \omega t$$

$$\text{Current Modulation: } I(V + \varepsilon \sin \omega t) = I(V) + \frac{dI}{dV} \varepsilon \sin \omega t$$

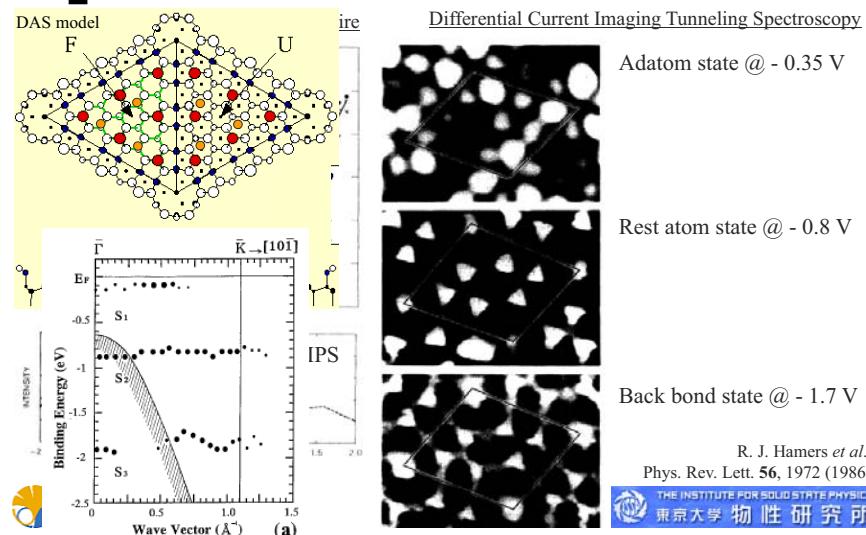
Detection by phase matching

$$\frac{dI}{dV} \propto \text{LDOS (Local Density Of States)}$$

C. Bai, *Scanning Tunneling Microscopy and its Application* (Springer, 1992)



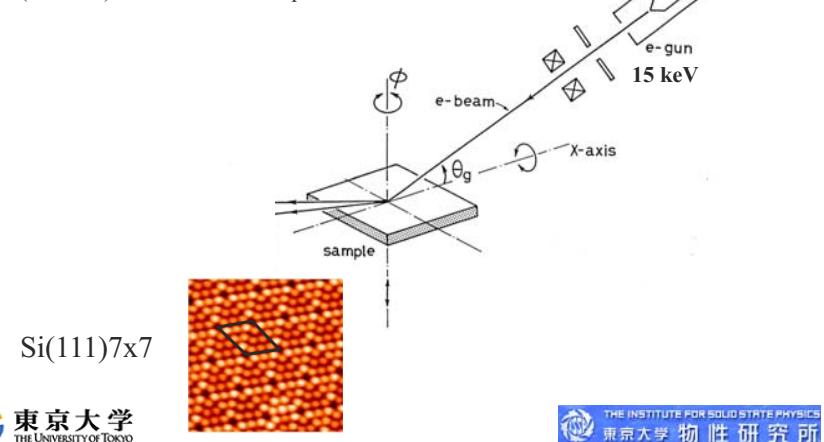
## Scanning Tunneling Spectroscopy



## Electron Diffraction

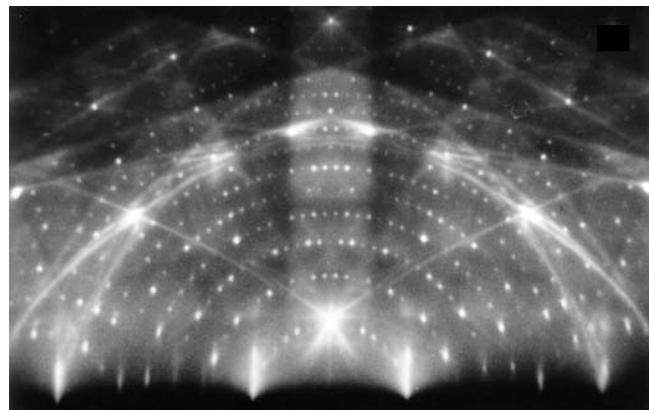
### Reflection High-Energy Electron Diffraction (RHEED)

(Electron) Wave diffracts at a periodic structure.

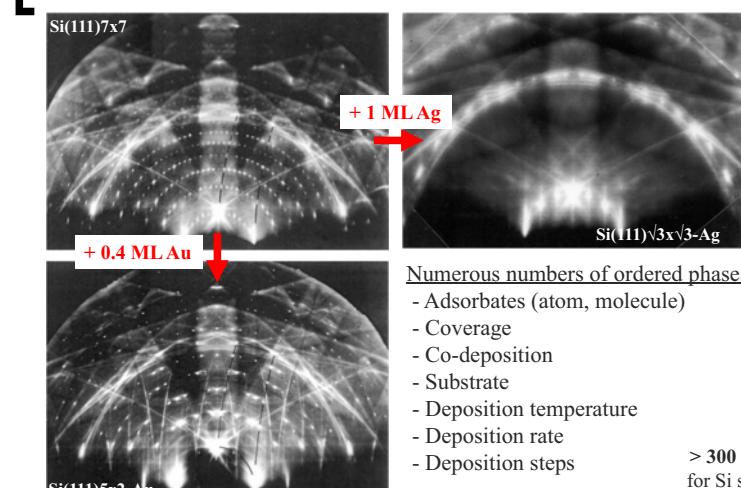


## Reflection High-Energy Electron Diffraction

### RHEED pattern of Si(111)7x7 at 15 keV



## Variations of ordered surface phases

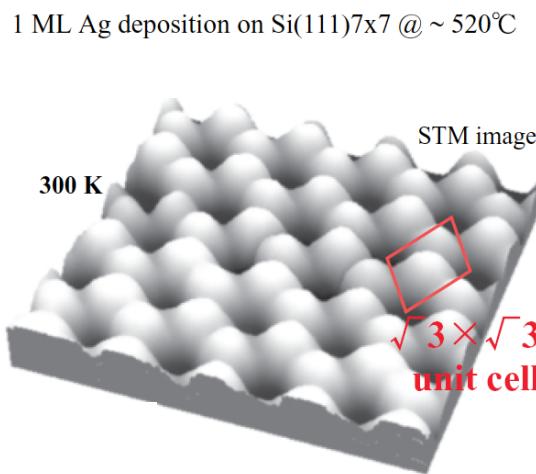
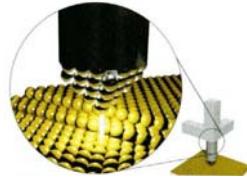


### Numerous numbers of ordered phases

- Adsorbates (atom, molecule)
  - Coverage
  - Co-deposition
  - Substrate
  - Deposition temperature
  - Deposition rate
  - Deposition steps
  - ....
- > 300 reported for Si substrate

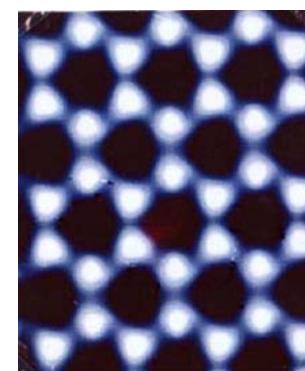
# [ Si(111) $\sqrt{3}\times\sqrt{3}$ -Ag ]

## ■ STM image

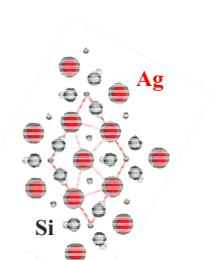
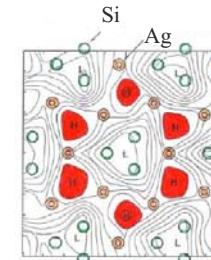


# [ Si(111) $\sqrt{3}\times\sqrt{3}$ -Ag ]

## ■ STM simulation



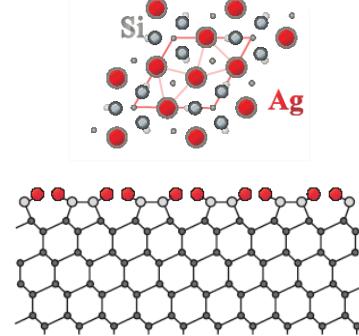
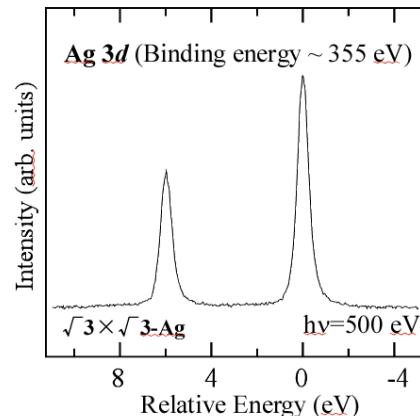
S. Watanabe *et al.*, Phys. Rev. B 44, 8330 (1991).



STM protrusions do not match the atom positions.

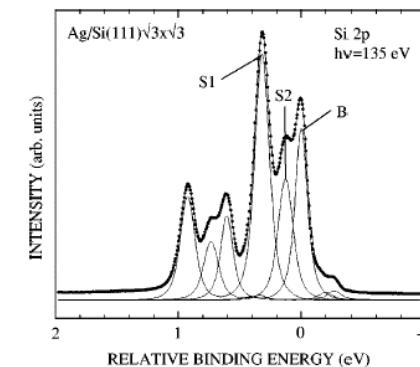
# [ Si(111) $\sqrt{3}\times\sqrt{3}$ -Ag ]

## ■ Atomic Structure and CLS spectra

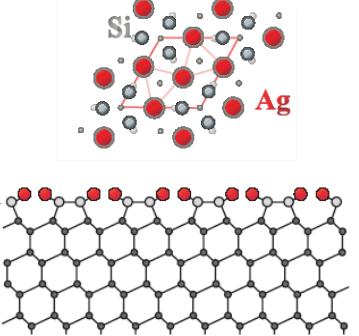


# [ Si(111) $\sqrt{3}\times\sqrt{3}$ -Ag ]

## ■ Atomic Structure and CLS spectra

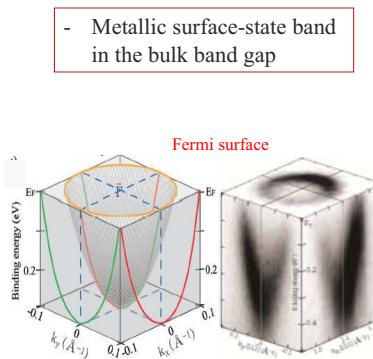
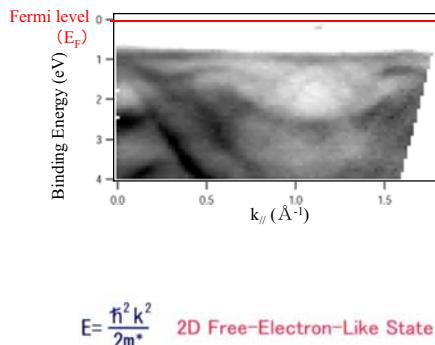


R.I.G Uhrberg *et al.*, Phys. Rev. B 65, 081305(R) (2002).



# [ Si(111) $\sqrt{3}\times\sqrt{3}$ -Ag ]

## ■ Electronic Structure

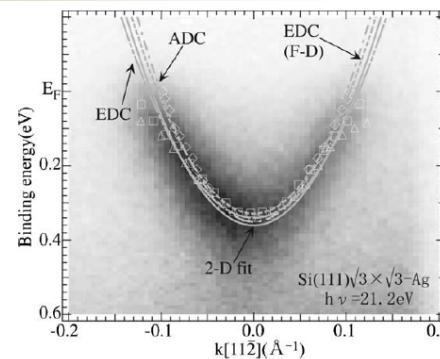


# [ Si(111) $\sqrt{3}\times\sqrt{3}$ -Ag ]

## ■ Electronic Structure

$$2\text{D-fit} \quad \chi^2 = \sum_i \left( \frac{E(k_i) - E_i}{w_i} \right)^2$$

$$E = \frac{\hbar^2 k^2}{2m^*} + E_0$$



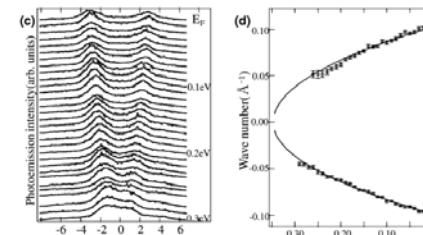
	$m^*/m_e$	$E_0$ (eV)	$k_F$ ( $\text{\AA}^{-1}$ )
EDC	$0.16 \pm 0.02$	$0.32 \pm 0.03$	$0.11 \pm 0.01$
ADC	$0.10 \pm 0.03$	$0.32 \pm 0.03$	$0.10 \pm 0.01$
2-D	$0.12 \pm 0.02$	$0.33 \pm 0.03$	$0.10 \pm 0.01$



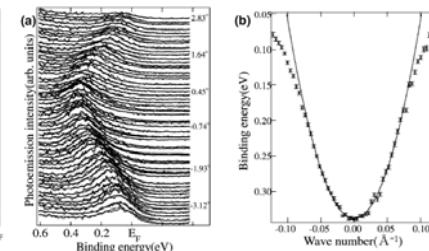
# [ Si(111) $\sqrt{3}\times\sqrt{3}$ -Ag ]

## ■ Electronic Structure

### Angle-Distribution Curves (ADC)



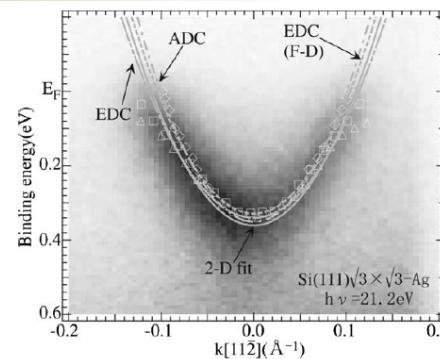
### Energy-Distribution Curves (EDC)



# [ Si(111) $\sqrt{3}\times\sqrt{3}$ -Ag ]

## ■ Electronic Structure

$$2\text{D-fit} \quad \chi^2 = \sum_i \left( \frac{E(k_i) - E_i}{w_i} \right)^2$$

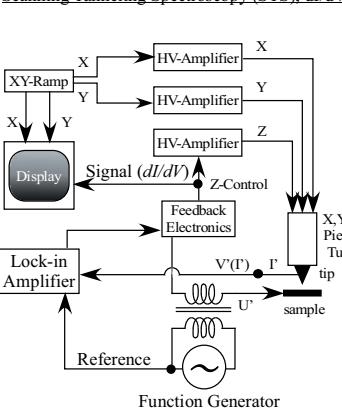


	$m^*/m_e$	$E_0$ (eV)	$k_F$ ( $\text{\AA}^{-1}$ )
EDC	$0.16 \pm 0.02$	$0.32 \pm 0.03$	$0.11 \pm 0.01$
ADC	$0.10 \pm 0.03$	$0.32 \pm 0.03$	$0.10 \pm 0.01$
2-D	$0.12 \pm 0.02$	$0.33 \pm 0.03$	$0.10 \pm 0.01$



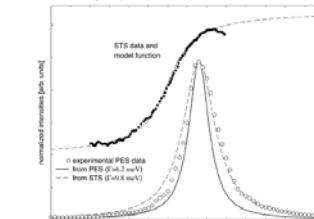
# [ Scanning Tunneling Spectroscopy ]

### Scanning Tunneling Spectroscopy (STS), $dI/dV$



G. Nicolay et al., Phys. Rev. B 62 1631 (2000).

Ag(111) LGap Surface State, STS and PES



$$\text{Bias Modulation: } V' = V + \varepsilon \sin \omega t$$

$$\text{Current Modulation: } I(V + \varepsilon \sin \omega t) = I(V) + \frac{dI}{dV} \varepsilon \sin \omega t$$

Detection by phase matching

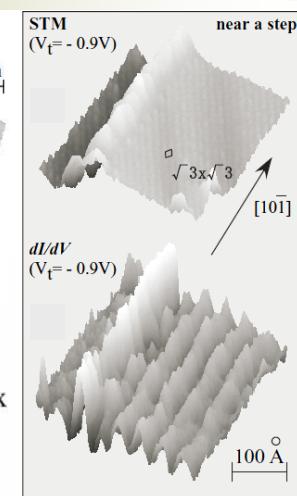
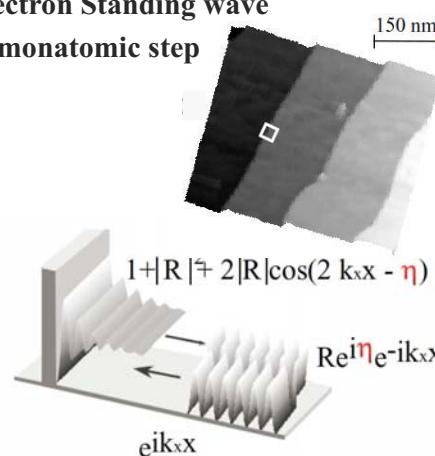
$$\frac{dI}{dV} \propto \text{LDOS (Local Density Of States)}$$

C. Bai, Scanning Tunneling Microscopy and its Application  
(Springer, 1992)



# [Si(111) $\sqrt{3}\times\sqrt{3}$ -Ag]

## ■ Electron Standing wave at monatomic step



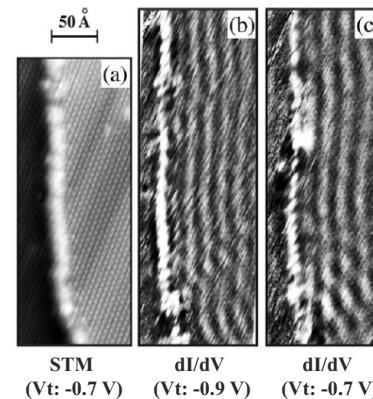
東京大学  
THE UNIVERSITY OF TOKYO

I. Matsuda *et al.*,  
Phys. Rev. Lett. 93, 236801 (2004).

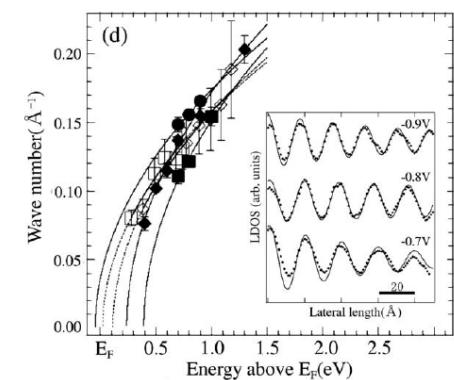
THE INSTITUTE FOR SOLID STATE PHYSICS  
東京大学 物性研究所

# [Si(111) $\sqrt{3}\times\sqrt{3}$ -Ag]

## ■ Electron Standing wave



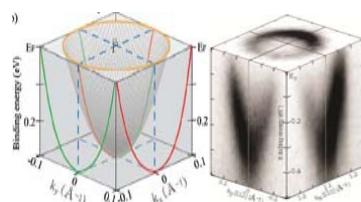
東京大学  
THE UNIVERSITY OF TOKYO



THE INSTITUTE FOR SOLID STATE PHYSICS  
東京大学 物性研究所

# [Si(111) $\sqrt{3}\times\sqrt{3}$ -Ag]

## ■ The 2-D Free electron metallic band



$$E = \frac{\hbar^2 k^2}{2m^*} + E_0$$

The values of  $m^*/m_e$ ,  $E_0$ ,  $k_F$  for analyses done by EDC, ADC, 2D fit, EDC corrected by the Fermi-Dirac distribution function, and STS

	$m^*/m_e$	$E_0$ (eV)	$k_F$ ( $\text{\AA}^{-1}$ )
EDC	$0.16 \pm 0.02$	$0.32 \pm 0.03$	$0.11 \pm 0.01$
ADC	$0.10 \pm 0.03$	$0.32 \pm 0.03$	$0.10 \pm 0.01$
2-D	$0.12 \pm 0.02$	$0.33 \pm 0.03$	$0.10 \pm 0.01$
EDC(FD)	$0.15 \pm 0.02$	$0.31 \pm 0.03$	$0.11 \pm 0.01$
STS	$0.13 \pm 0.03$		

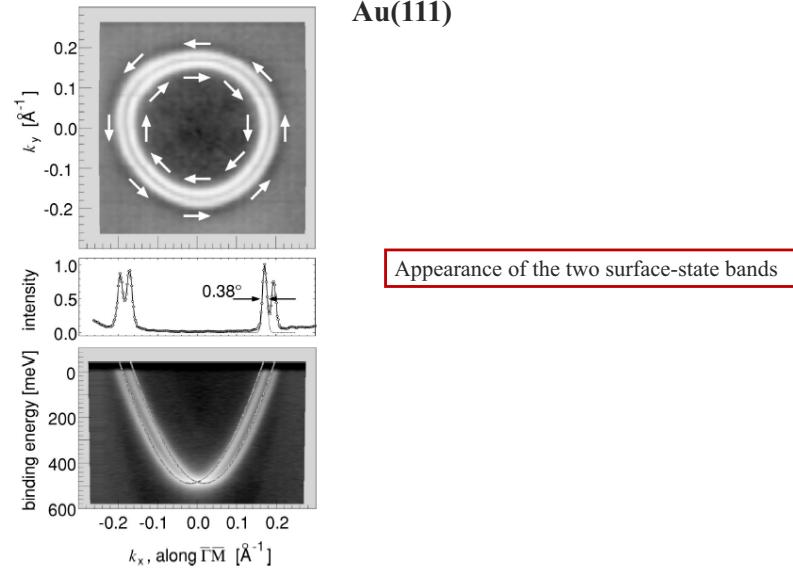
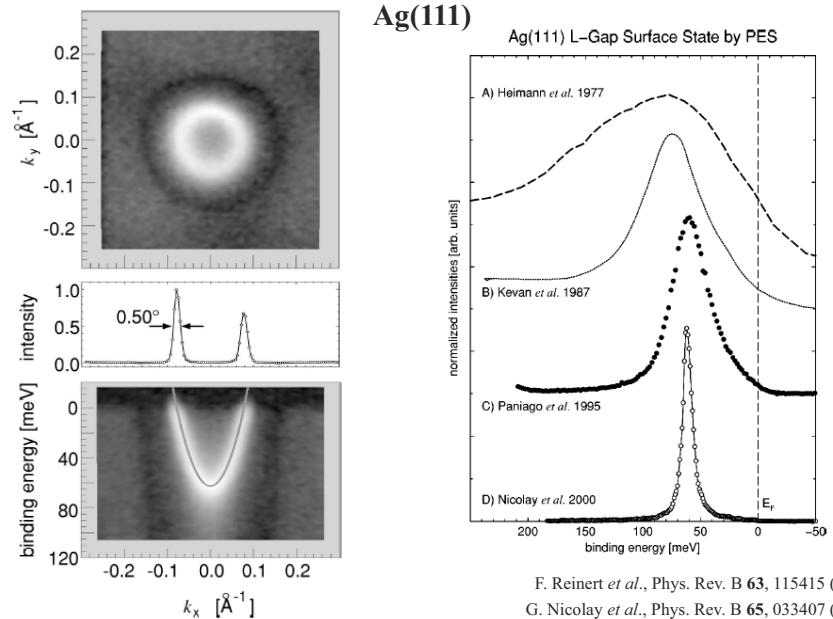
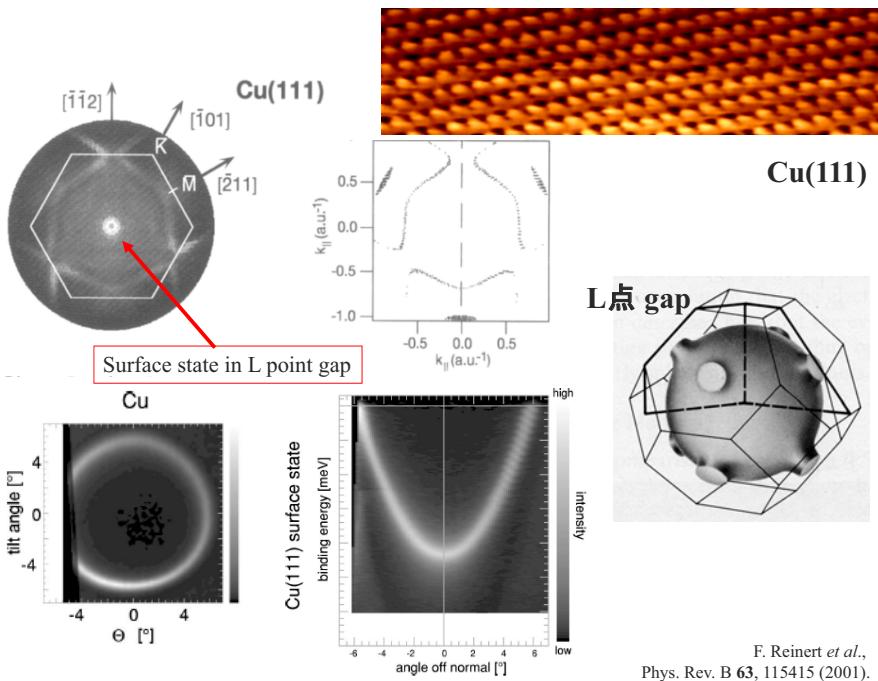
東京大学  
THE UNIVERSITY OF TOKYO

Metal surface

Electronic structure

東京大学  
THE UNIVERSITY OF TOKYO

THE INSTITUTE FOR SOLID STATE PHYSICS  
東京大学 物性研究所



## Surface Rashba effect

E. I. Rashba, Sov. Phys. Solid State 2, 1109(1960)

Kramers degeneracy :  $E(k,\uparrow)=E(k,\downarrow)$

Time reversal symmetry:  $E(k,\uparrow)=E(-k,\downarrow)$

Space inversion symmetry:  $E(k,\uparrow)=E(-k,\uparrow)$

Breakdown at a surface

Spin-split bands

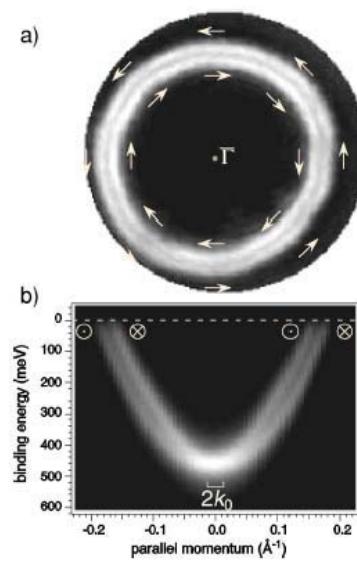
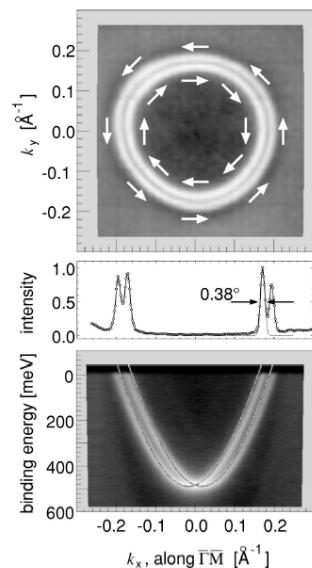
$$\text{Spin-Orbit Coupling Hamiltonian } H_{SOC} = \frac{\hbar}{4m_e^2 c^2} (\vec{\sigma} \cdot (\nabla \vec{V}) \times \vec{p}) (\alpha \vec{s} \cdot \vec{L})$$

$$-\frac{\hbar^2}{2m} \nabla^2 \psi(\vec{r}) = E \psi(\vec{r})$$

$$E = \frac{\hbar^2 k^2}{2m}$$

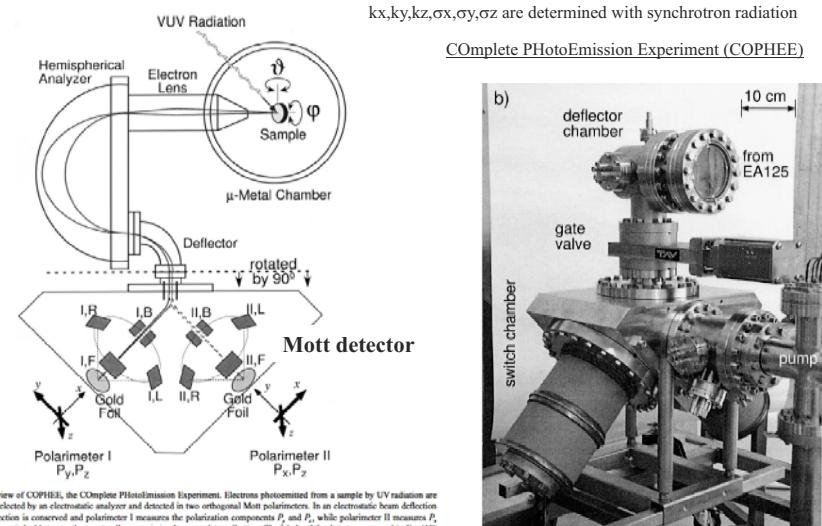
$$E = \frac{\hbar^2 k^2}{2m} \pm \alpha \hbar k$$



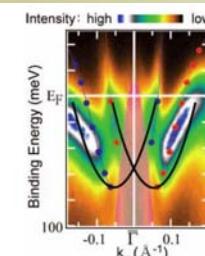


### Fermi surface mapping with spin-resolved photoemission spectroscopy

H. Moritz *et al.*, J. Elec. Spec. Rel. Phenom. **124**, 263 (2002).



### Surface Rashba effect



A band diagram of the Bi(111) surface states taken at photon energy of 21.2 eV.<sup>11,12</sup> Dispersion curves of the theoretical calculation results and the simple Rashba model are overlapped on the figure.

**Table 1.** Rashba parameters for various crystal surfaces<sup>13</sup>: Atomic number ( $Z$ ), the Rashba constant ( $|\alpha_R|$ ), the Rashba momentum ( $k_R$ ), the Rashba energy ( $E_R$ ).

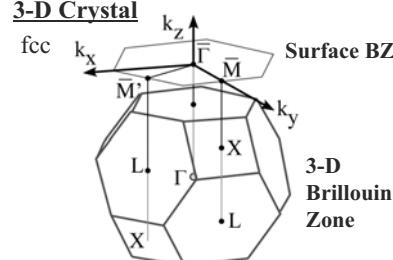
Surface	$Z$	$ \alpha_R (\text{eV\AA})$	$k_R(\text{\AA}^{-1})$	$E_R(\text{meV})$	Ref.
Ag(111)	47	0.03	0.004	<0.2	13, 14)
Au(111)	79	0.33	0.012	2.1	14, 15)
Bi(111)	83	0.56	0.05	14	16)
$\sqrt{3} \times \sqrt{3}$ -Pb/Ag(111)	82/47	1.42	0.03	21	17)
$\sqrt{3} \times \sqrt{3}$ -Bi/Ag(111)	83/47	3.05	0.13	200	18)

## Metal films

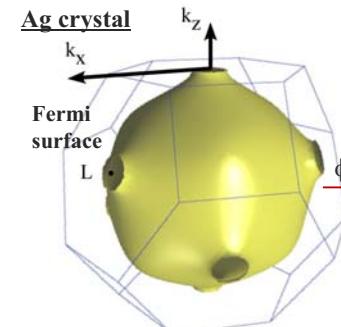
### Electronic structure



3-D Crystal

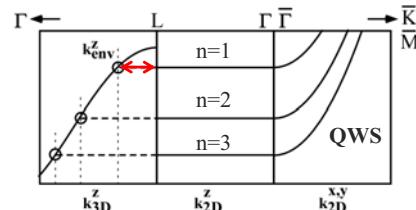


Ag crystal

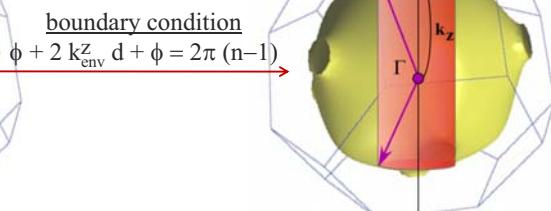


Quantum Confinement Effect

Quantization of a bulk band

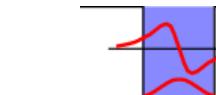


boundary condition



## - Quantum Film

Quantum Size effect, Quantum Confinement Effect



Free electron model

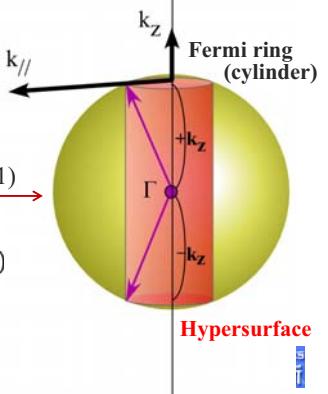
Fermi sphere

$$E = \frac{\hbar^2}{2m^*} k^2$$

momentum space

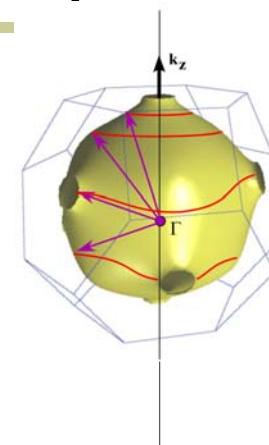
A problem of particles (electrons) in a box

Energetically quantized electronic states  
Quantum Well States (QWS)



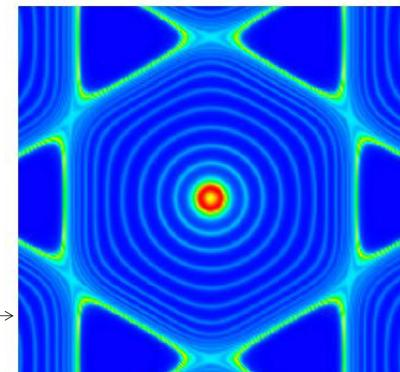
Hypersurface

Ultrathin Ag(111) film (quantum film)



Fermi surface of Ag(111) slab calculation

(15 ML-Ag(111) free-standing slab)

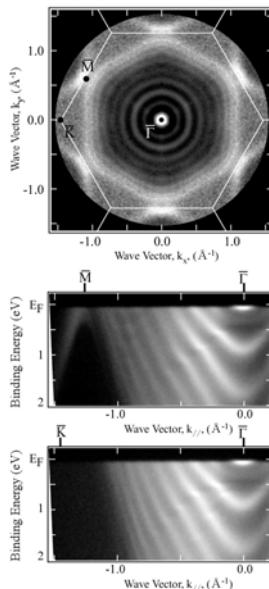


6-fold symmetry

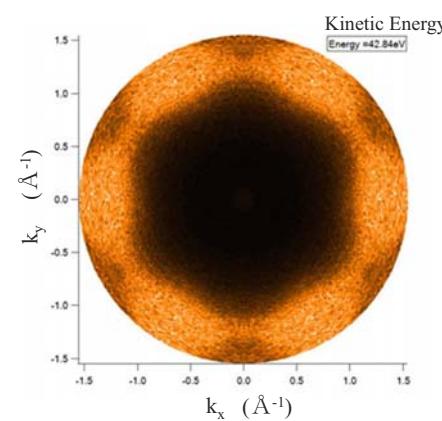
weight:  
spectral intensity



### Epitaxial 15ML-Ag(111) film on Si(111)

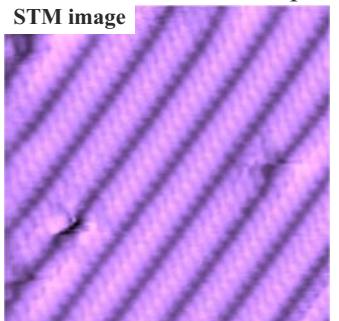


In addition to band features expected,  
new features, kinks, hexagons at  $\Gamma$ , are observed.



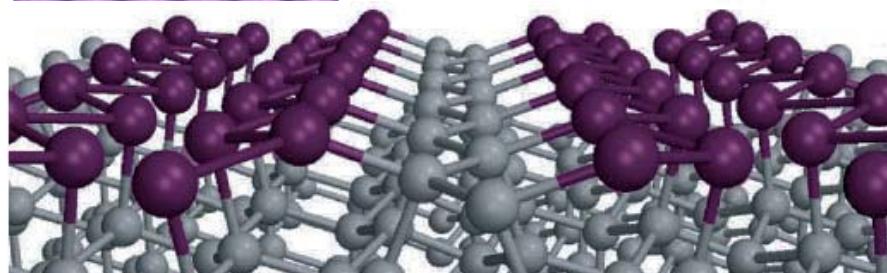
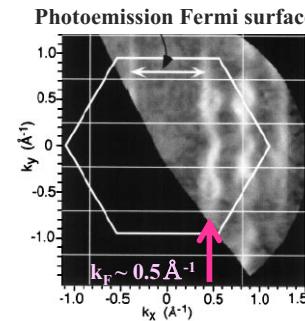
### Choice in Semiconductor Surface Science

A periodic array of atomic wires:



Si(111)4x1-In

$a_{int} = 1.3 \text{ nm}$



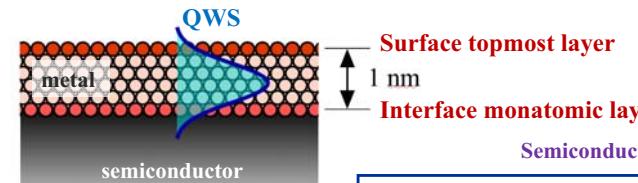
### Our interests

#### Quantum Size effect, Quantum Confinement Effect

Thickness : Semiconductor  
de Broglie wave,  $\sim 100 \text{ nm}$   
Metal  
Fermi wavelength,  $\sim 1 \text{ nm}$

*Large ratio of a surface (interface) monatomic layer to film atomic layers: > 1 / 10*

#### Ultrathin film (2-D growth)



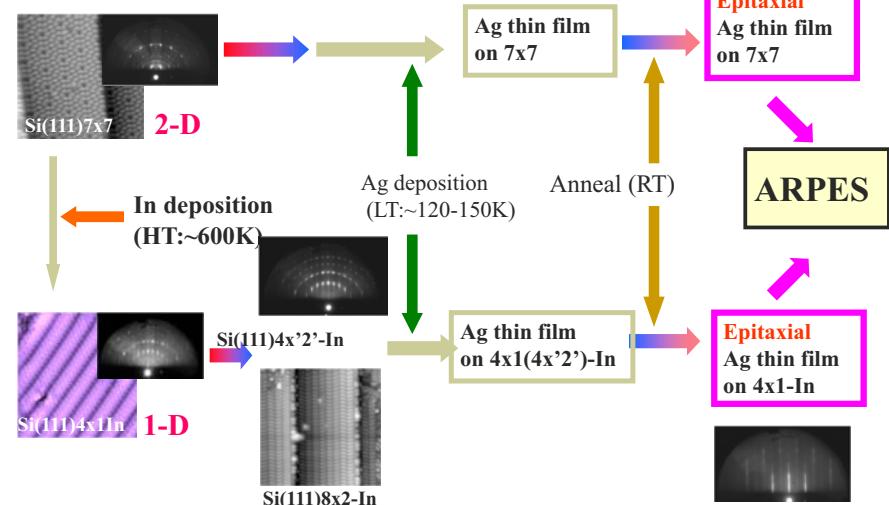
Semiconductor Surface Science

Engineering Fermi surface topology  
Electronic topological transition  
by an interface monatomic layer

### Experiments

#### Exchange of interface layer between film and substrate

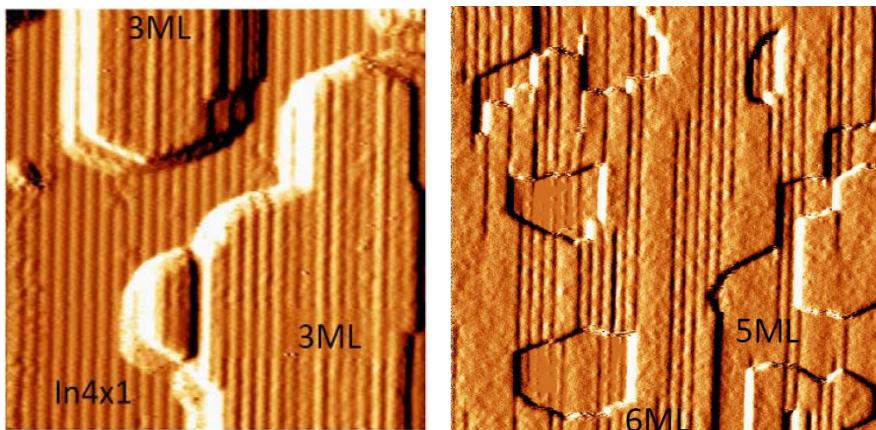
Substrate: vicinal Si(111) (1.8° -off)



## Results & Discussions

STM: Ag film / Si (111)4x1-In

T. Uchihashi *et al.*, Phys. Rev. Lett. **96**, 136104 (2006)



## Results & Discussions

BL3.2 VUV Elettra, Italy

hv=50eV room temperature

Ag film (~1nm) / Si (111)4x1-In

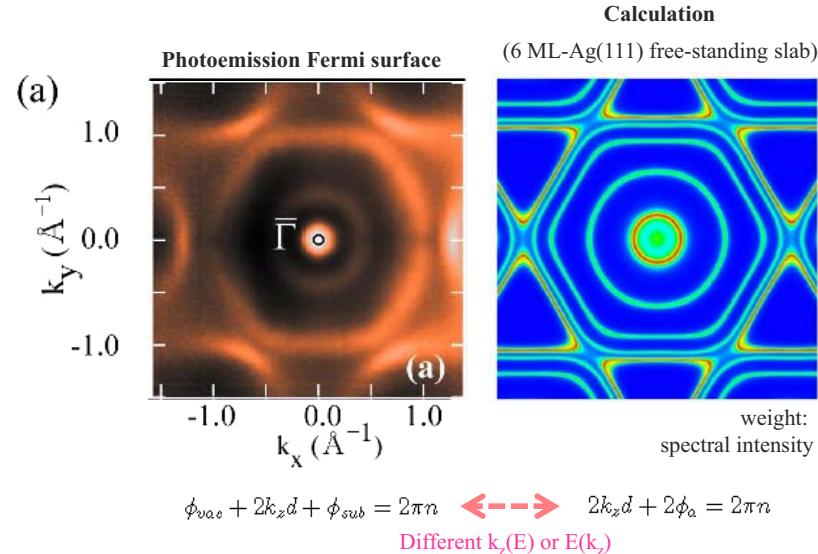
Ag film (~1nm) / Si (111)7x7



## Results & Discussions

BL3.2 VUV Elettra, Italy

ARPES: Ag film (~1nm) / Si (111)7x7



## Results & Discussions

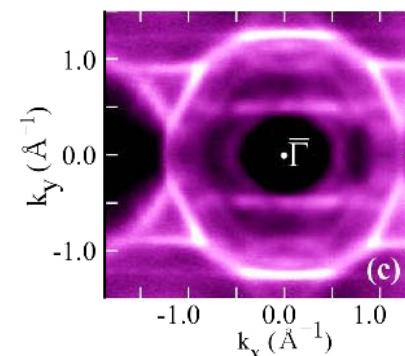
BL3.2 VUV Elettra, Italy

ARPES: Ag film (~1nm) / Si (111)4x1-In

hv=50eV

room temperature

Photoemission Fermi surface



## Solid Surface

Playgrounds for low-dimensional physics



## Surface electronic structures

### Spin-orbit interaction

Dirac equation:

$$\frac{\mathbf{p}^2}{2m} - \frac{e\hbar\sigma \cdot \mathbf{p} \times \xi}{4m^2c^2} + \frac{e\hbar}{2m}\sigma \cdot \mathbf{B} - \frac{e\hbar^2}{8m^2c^2}\nabla \cdot \xi\Psi = E\Psi$$

### Surface Rashba effect

$$E^{\uparrow\downarrow}(k) = \frac{\hbar^2 k^2}{2m} \pm \frac{\hbar^2}{2m^2 c^2} \left( \frac{\partial V}{\partial z} \right) k$$

$$= \frac{\hbar^2 k^2}{2m} \pm \frac{\hbar^2 k_R k}{m} = \frac{\hbar^2 k^2}{2m} \pm \alpha_R k$$

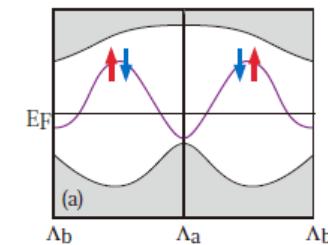
### Quantum Spin Hall Phase



## Surface electronic structures

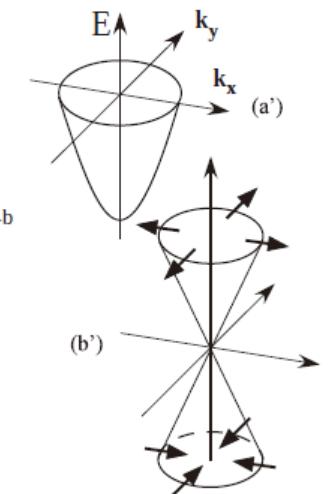
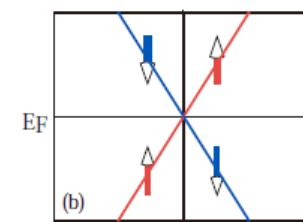
### Schroedinger electron

$$\frac{\mathbf{p}^2}{2m}\Psi = E\Psi$$



### Dirac-Weyl electron

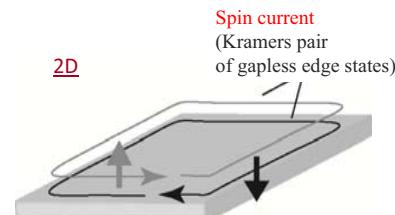
$$(c\alpha \cdot \mathbf{p})\Psi = E\Psi$$



## Quantum spin Hall phase (topological insulator)

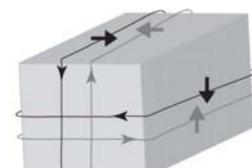
Kane, Mele, PRL(2005), Bernevig, Zhang, PRL (2005)

- bulk = gapped (insulator)
- gapless edge states -- carry spin current, topologically protected robust against nonmagnetic impurities
- spin analogue of the quantum Hall effect “new state of matter”
- no field required



2D

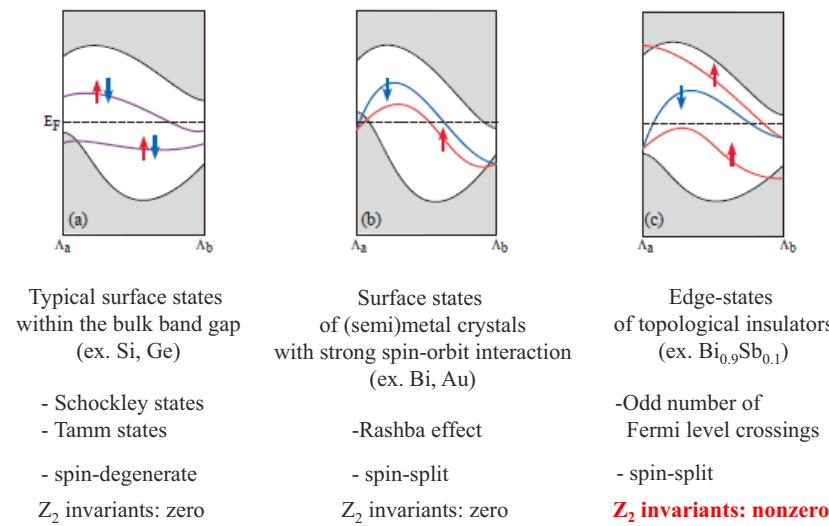
3D



1D-edge states

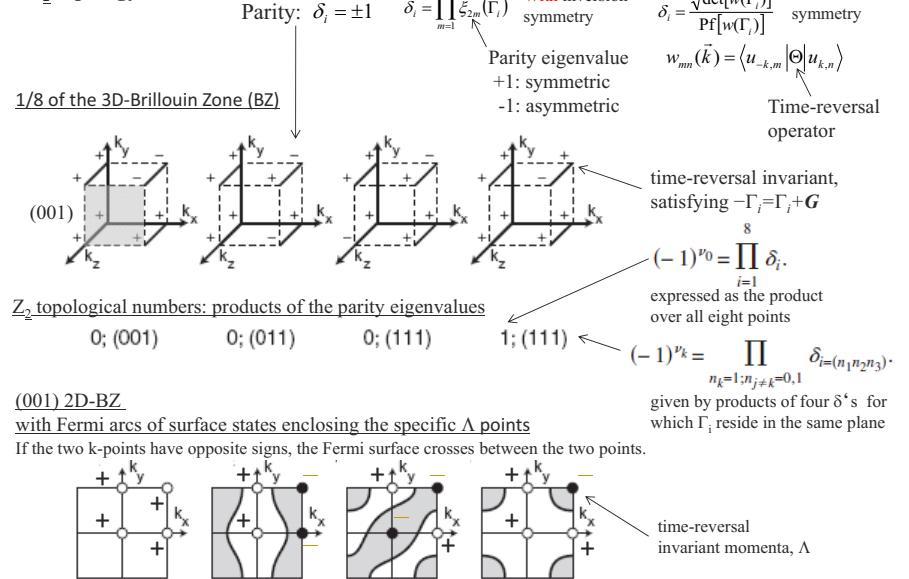
2D-edge states  
surface states

## Surface electronic structures

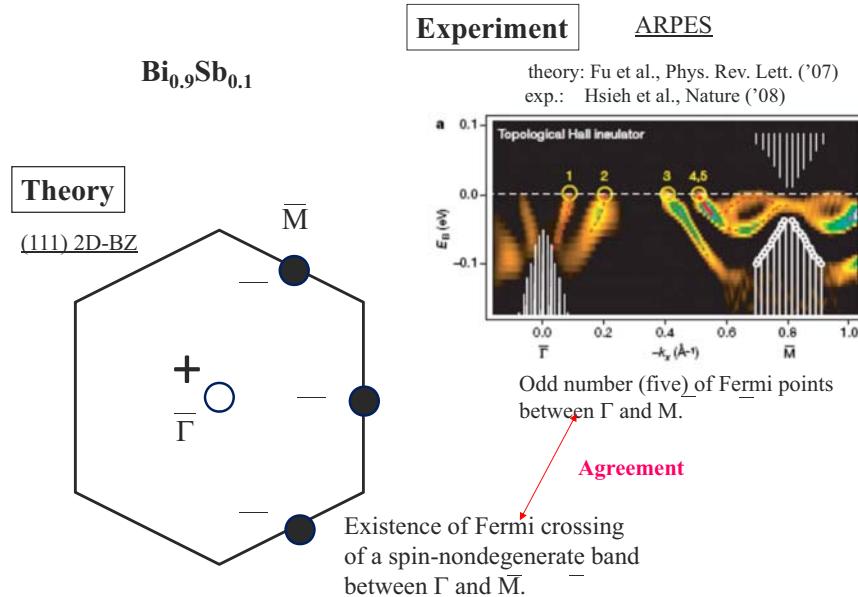


## Topological band theory

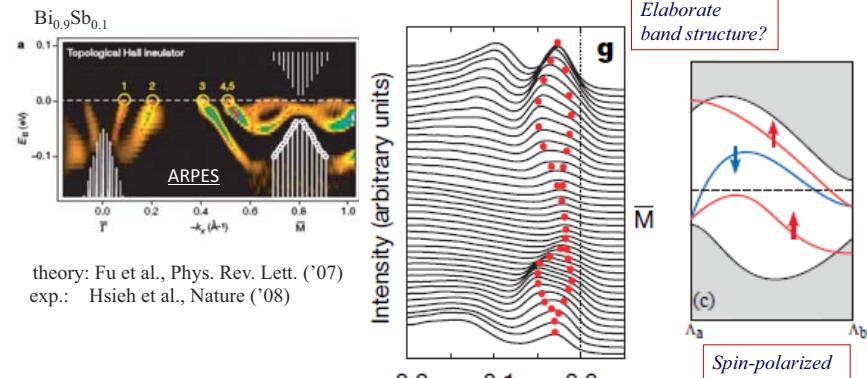
### $Z_2$ topology in band structure



## The $\text{Bi}_{1-x}\text{Sb}_x$ case



## Motivation



### Spin- and angle(momentum)-resolved photoemission spectroscopy

How do we determine momentum of electrons?

Electron spectrometers from VG, Scienta, Omicron, Specs....

How do we determine their spin coordinates?

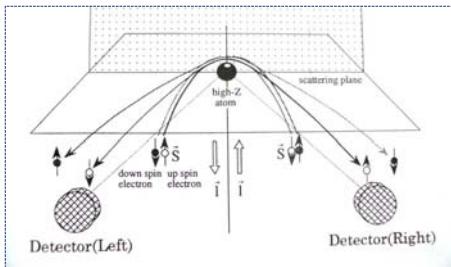
Spin detector, Spin polarimeter

## Spin-detector (Mott detector)

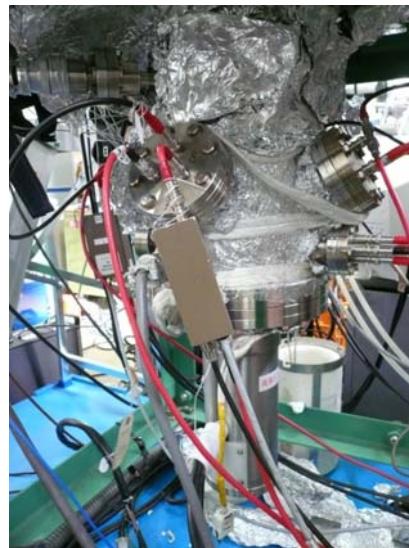
### 25 kV-Compact Mott detector

by A. Kakizaki *et al.*

S. Qiao, *et al.*, Rev. Sci. Instrum. **68**, 4390 (1997).

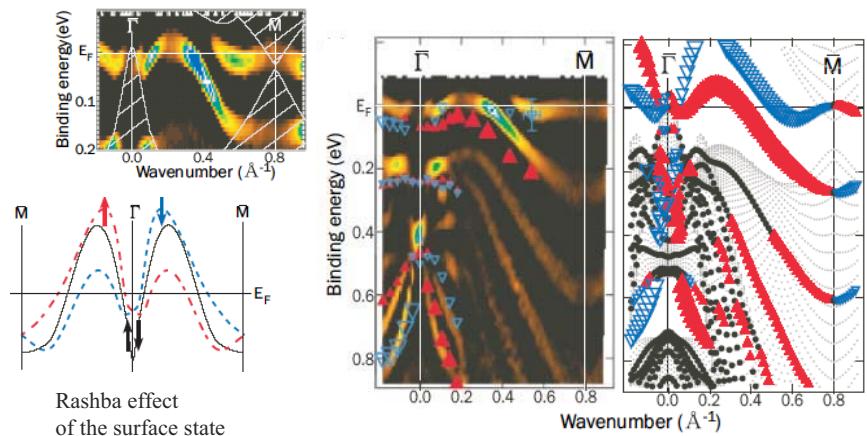


- 25 keV electrons
- spin-orbit interaction
- Au target



## Spin-detector (Mott detector)

### Spin-resolved band mapping of Bi crystal film with a 25 kV-Compact Mott detector

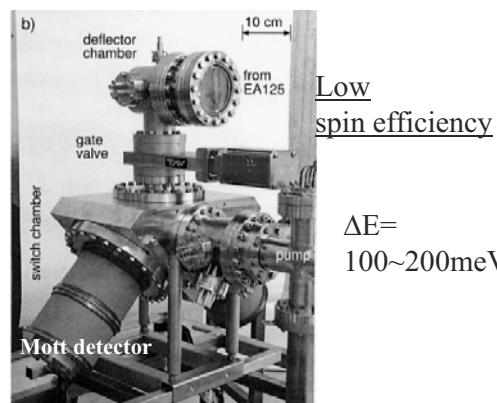


T.Hirahara *et al.*, Phys. Rev. B **76**, 153305 (2007).

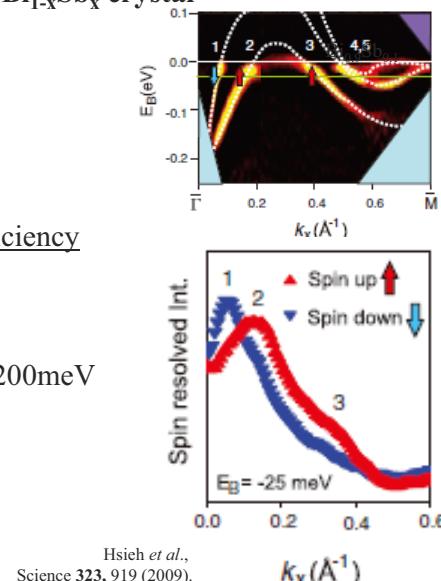
## Spin-detector (Mott detector)

### Spin-resolved band mapping of $\text{Bi}_{1-x}\text{Sb}_x$ crystal with a Compact Mott detector

Complete PHotoEmission Experiment (COPHEE)



H. Moritz *et al.*,  
J. Elec. Spec. Rel. Phenom. **124**, 263 (2002).



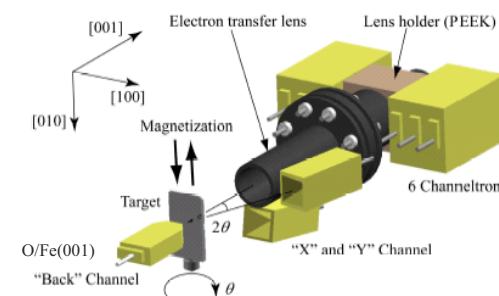
Hsieh *et al.*,  
Science **323**, 919 (2009).

## Spin-detector (VLEED detector)

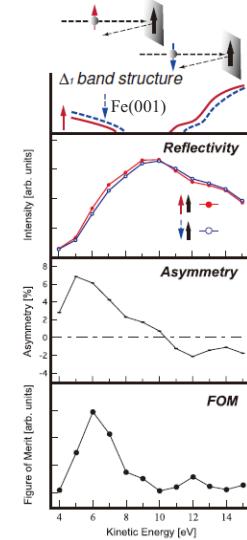
### Very Low- Energy Electron Diffraction (VLEED) detector

by T. Okuda *et al.*

T. Okuda, Y. Takeichi, Yuuki Maeda, A. Harasawa, I. Matsuda, T. Kinoshita, and A. Kakizaki, Rev. Sci. Instrum. **79**, 123117 (2008).



- 6 eV electrons
- exchange interaction
- Fe, O/Fe target



## Spin-detector (VLEED detector)

SPECS-PHOIBOS150+VLEED detector



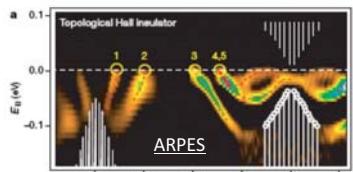
High-efficient spin detection (100 times better than the Mott detector)

→ A combination with high-resolution analyzer

$$\varepsilon = (1.0 \pm 0.2) \times 10^{-2}, \Delta E < 30 \text{ meV}$$

## Motivation

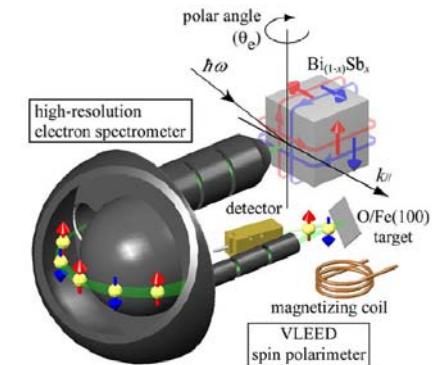
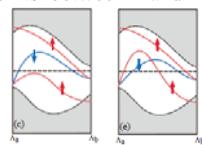
$\text{Bi}_{0.9}\text{Sb}_{0.1}$



theory: Fu et al., Phys. Rev. Lett. ('07)  
exp.: Hsieh et al., Nature ('08)

Odd number (five) of Fermi points between  $\bar{\Gamma}$  and  $\bar{M}$ .

Spin-polarized band structure?

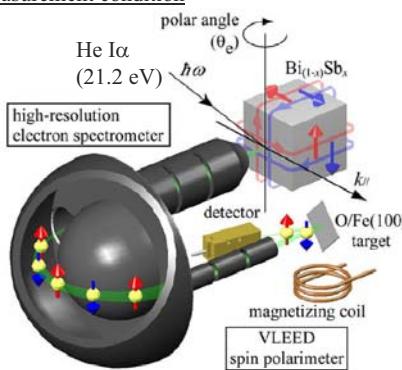


high-resolution spin-resolved photoemission spectroscopy

## Results and Discussion

high-resolution spin-resolved photoemission spectroscopy

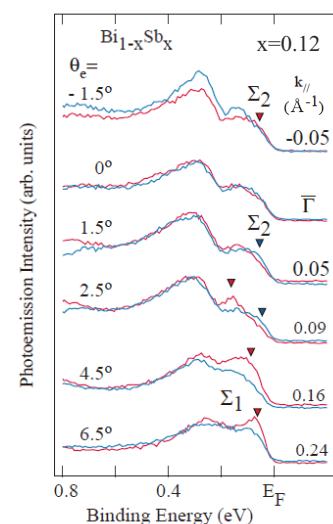
Measurement condition



$$\Delta E = 50 \text{ meV}, \Delta \theta = \pm 1^\circ$$

T~130 K

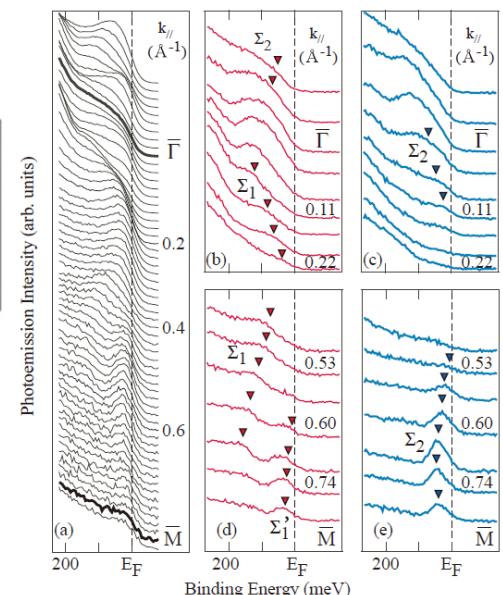
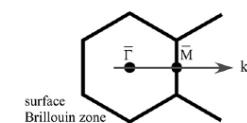
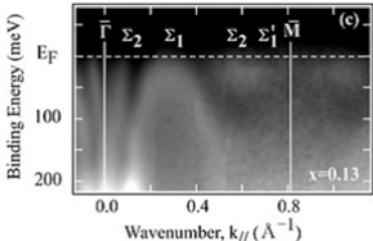
$S_{\text{eff}} = 0.32 \pm 0.04$ ,  
determined by the polarization  
of secondary electrons from Fe(001).



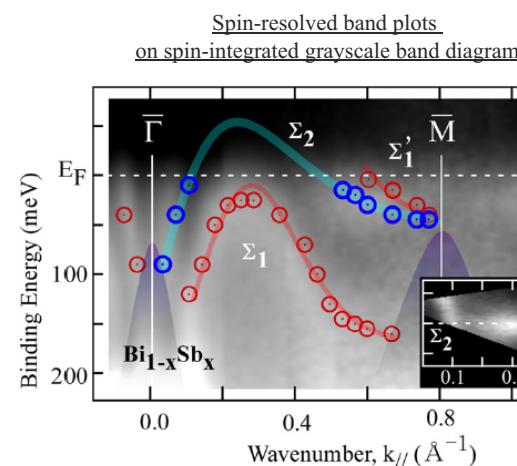
## Results and Discussion

$\text{Bi}_{1-x}\text{Sb}_x$

x=0.12, 0.13

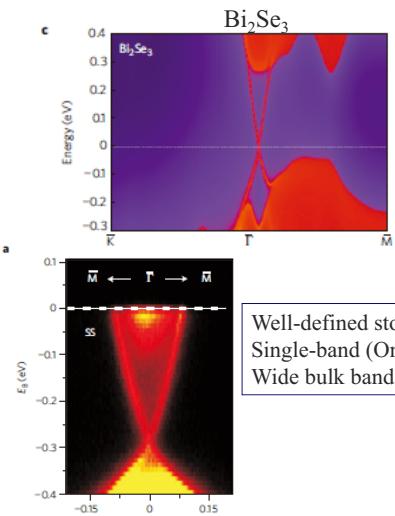


## Results and Discussion

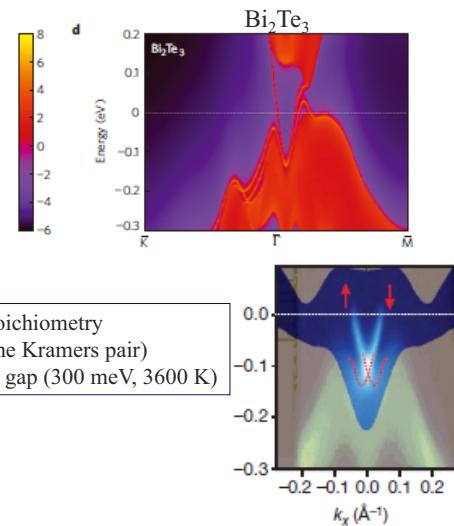


Edge-states of topological insulators (ex.  $\text{Bi}_{0.9}\text{Sb}_{0.1}$ )  
- Odd number of Fermi level crossings  
- spin-split  
- **Z<sub>2</sub> invariants: nonzero**

### The second generation samples



H.Zhang et al., Nature Phys. 5 438 (2009).



D. Hsieh et al., Nature 460 1101 (2009).

## Summary

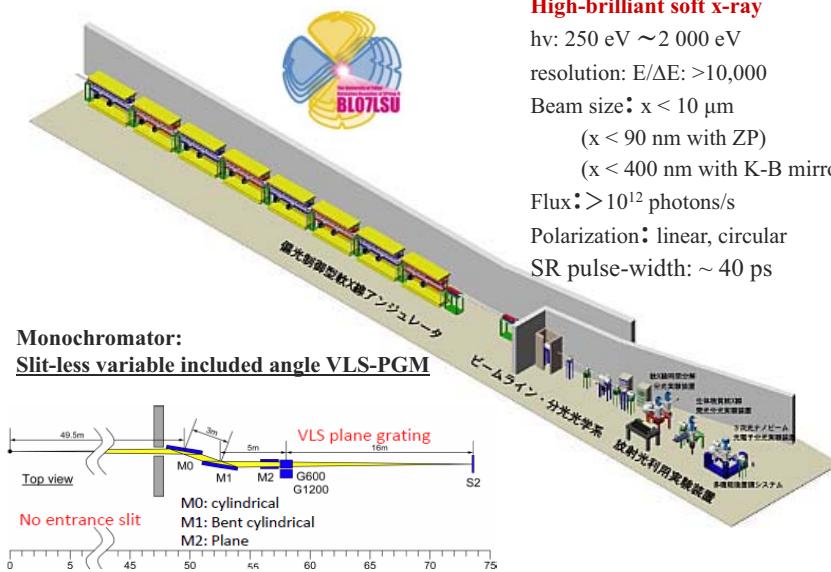
- Surface Science is everywhere. Global to Atomic scale.
- For solid/vacuum interface (solid surface), we have advantages of
  - Visualization of atomic configuration and electron density (LDOS) distribution in atomic scale
  - Direct determination of electronic structure (band, Fermi surface, spin, etc...)
- Solid surfaces are important playgrounds for studying low-dimensional physics.

Photoemission spectroscopies with synchrotron radiation are the important experimental tools.

## Frontier Spectroscopy experiments at SPring-8 BL07LSU: with time-resolution and at nano-space



## SPring-8 BL07LSU



## SPring-8 BL07LSU

### Four spectroscopy end-stations



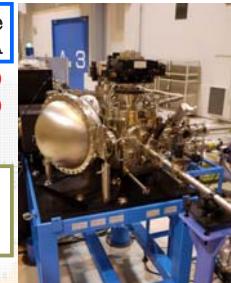
#### Time-Resolved soft X-ray spectroscopy station TR-SX spectroscopy

Time-resolved angle-resolved photoemission spectroscopy with a 2D-ARTOF spectrometer and fs-pulse lasers



#### 3D-scanning photoelectron microscope 3D nano-ESCA

Spatial resolution: 50 nm (x,y)  
Depth profile : 0.1 nm (z)



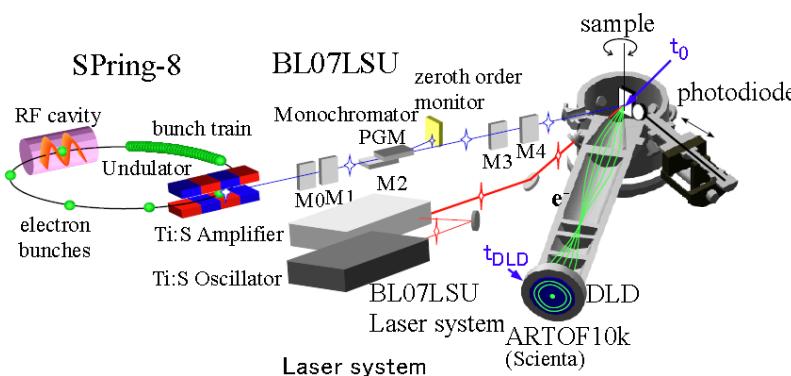
#### Ultra high-resolution soft X-ray emission spectroscopy HORNET

Ultimate resolution  
Measurement of solid, liquid, gas

#### Free-Port station

Open for experimental system of users

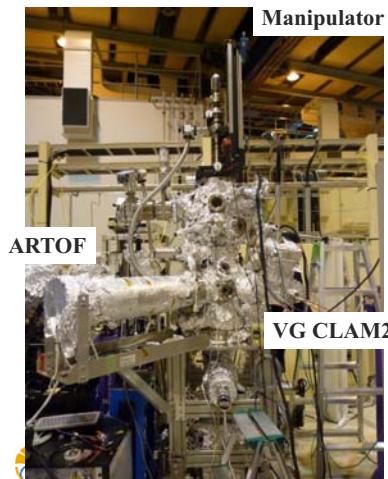
### Time-Resolved soft X-ray spectroscopy station TR-SX spectroscopy



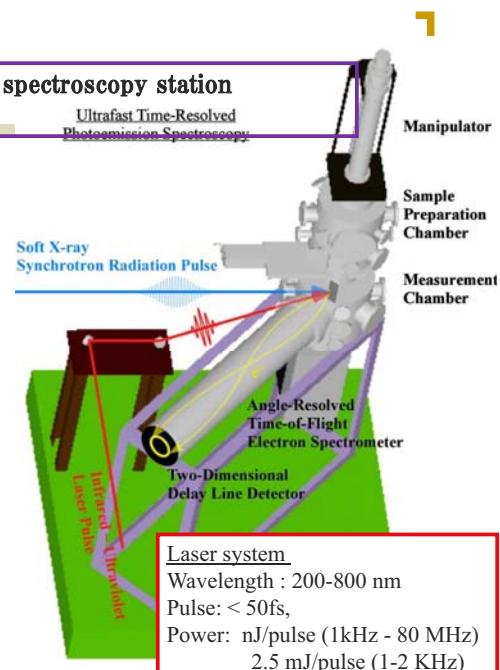
### Time-Resolved soft X-ray spectroscopy station TR-SX spectroscopy

Ultrafast Time-Resolved Photoemission Spectroscopy

#### The measurement system



Manipulator



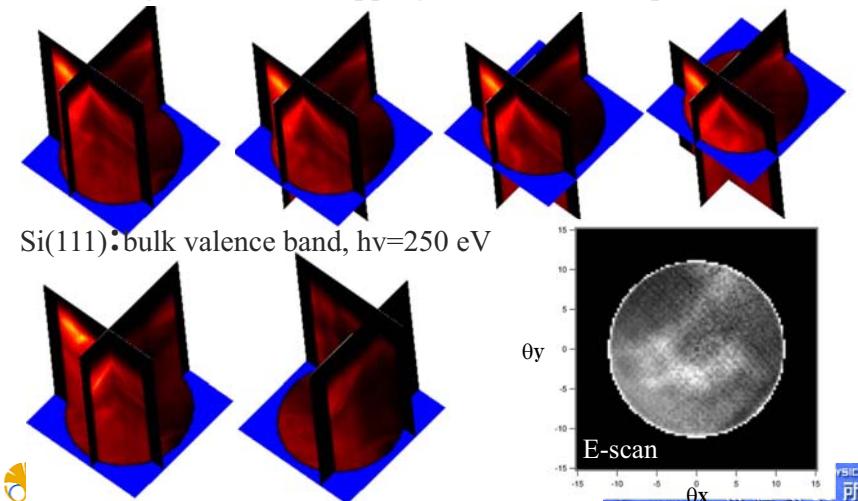
#### Laser system

Wavelength : 200-800 nm  
Pulse: < 50fs,  
Power: nJ/pulse (1kHz - 80 MHz)  
2.5 mJ/pulse (1-2 KHz)

Time-Resolved soft X-ray spectroscopy station  
TR-SX spectroscopy

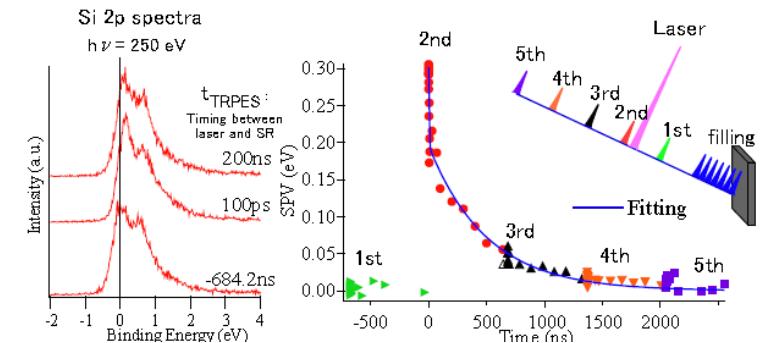
$\theta_x, \theta_y$  range =  $\pm 12.5^\circ$   
( $\theta_x, \theta_y$ , Max. range =  $\pm 15^\circ$ )  
Energy range = 17.5 eV

- 2-D angle-resolved mapping **without** the sample rotation



Time-Resolved soft X-ray spectroscopy station  
TR-SX spectroscopy

Pump(laser)-Probe(synchrotron radiation) time-resolved photoemission experiments on relaxation after the surface photovoltaic effect of Si(111)7x7

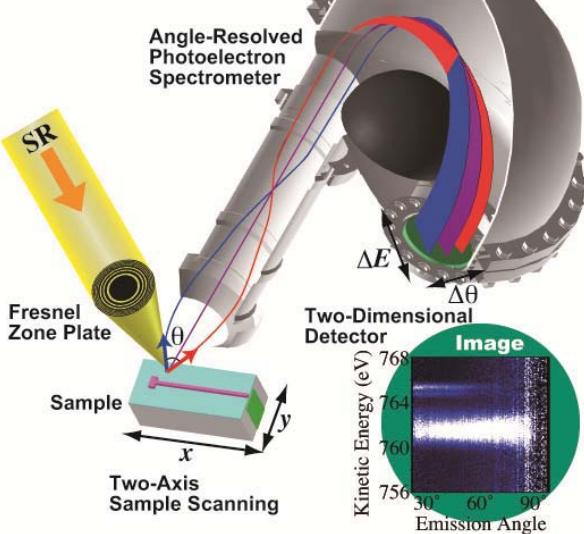
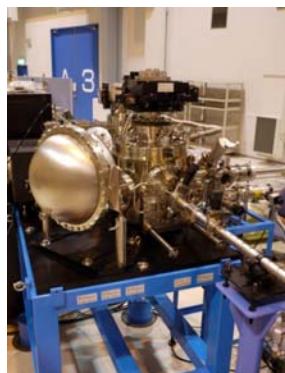


東京大学  
THE UNIVERSITY OF TOKYO

THE INSTITUTE FOR SOLID STATE PHYSICS  
東京大学 物性研究所

3D-scanning photoelectron microscope

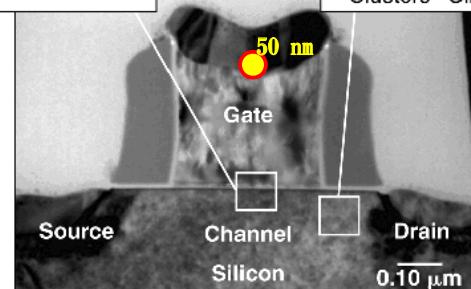
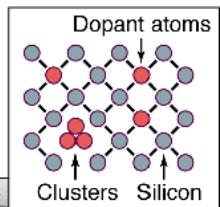
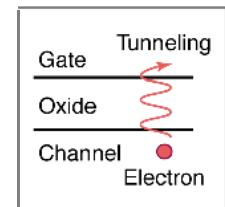
**3D nano-ESCA**



3D-scanning photoelectron microscope  
3D nano-ESCA

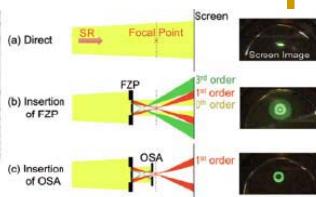
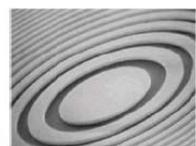
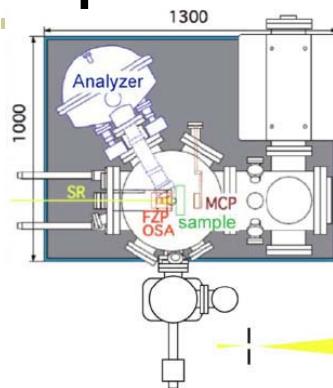
Element and chemical analysis  
in nano-region

東京大学  
THE UNIVERSITY OF TOKYO



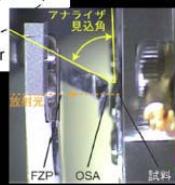
THE INSTITUTE FOR SOLID STATE PHYSICS  
東京大学 物性研究所

3D-scanning photoelectron microscope  
3D nano-ESCA



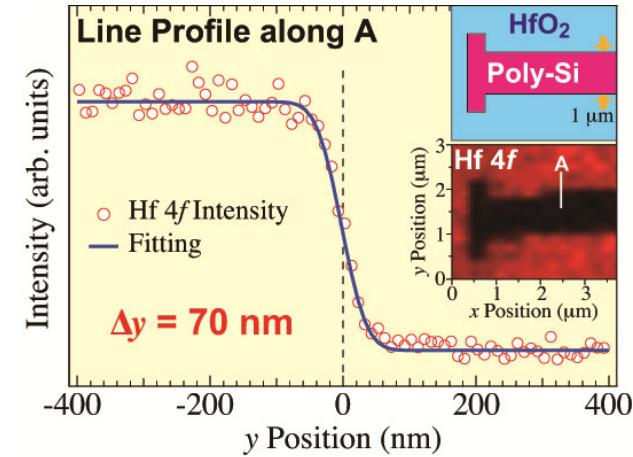
SPEM  
+  
depth profiling by  
Angle Resolved  
technique with  
MEM analysis

High-resolution angle-resolved electron  
spectrometer (VG-Scienta R3000)



FZP  
OSA  
試料

3D-scanning photoelectron microscope  
3D nano-ESCA



東京大学  
THE UNIVERSITY OF TOKYO

THE INSTITUTE FOR SOLID STATE PHYSICS  
東京大学 物性研究所



Thank you for your kind attentions.